

# Flat top beam interferometer to depress mirror thermal noise

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- Erika D'AMBROSIO
- Danièle FOREST
- Bernard LAGRANGE
- Christophe MICHEL
- Nazario MORGADO
- Alban REMILLIEUX
- Marco TARALLO
- LMA Lyon/EGO
- Caltech/LIGO

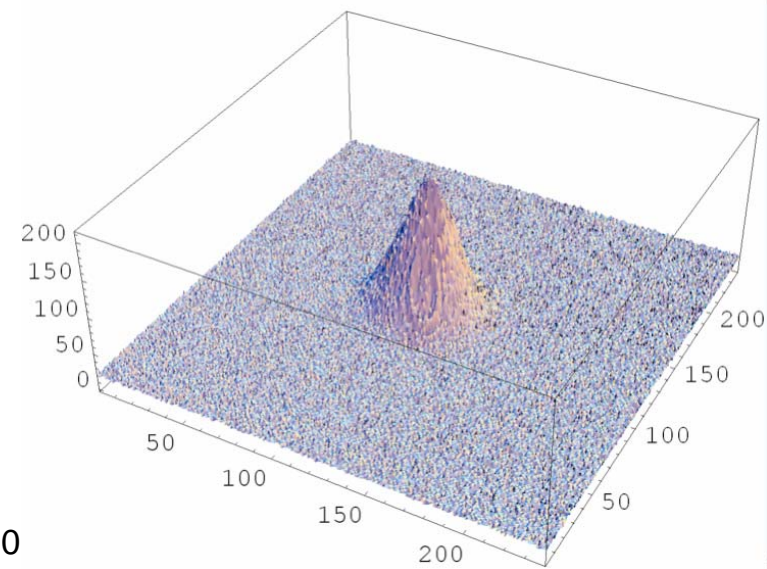


# Outline

- Interferometer lab status
  - (Marco Tarallo)
- Mirror production status
  - (Alban Remillieux)
- Mirror analysis
  - (Erika D'Ambrosio and Juri Agresti)

# Lab Status (Marco)

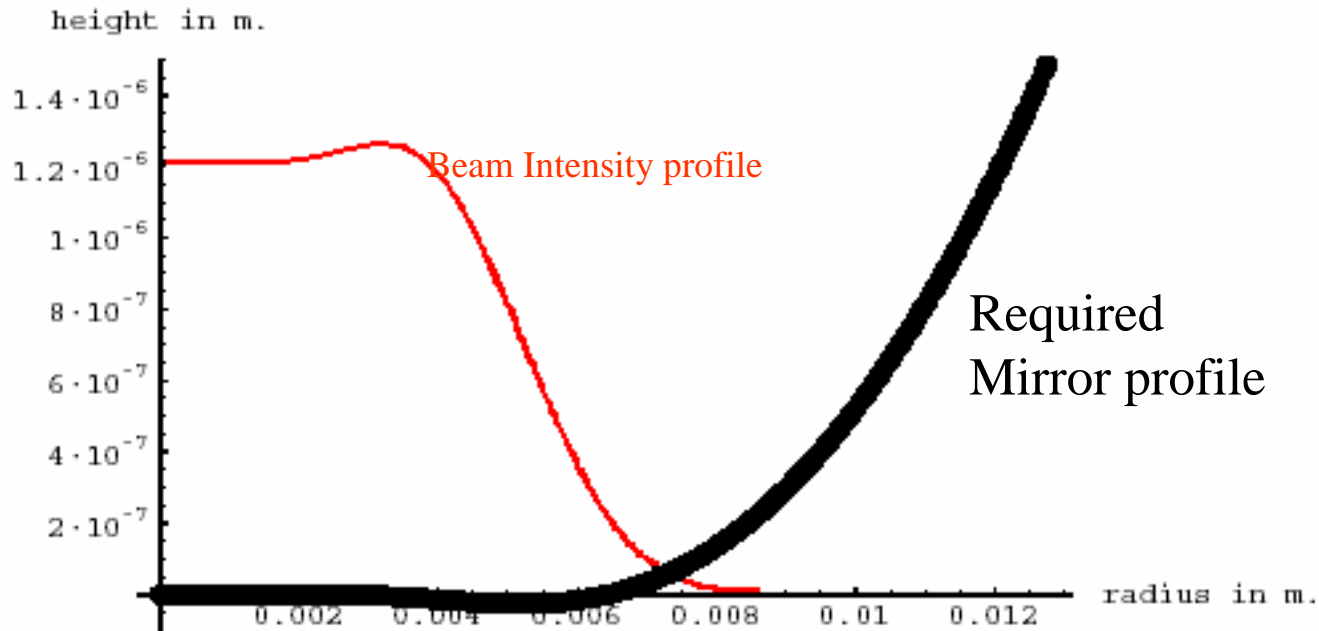
- Asbestos removal and lab re-hab lasted more than expected
- Will start unwrapping cabinets and equipment and realigning optical tables by Easter
- Prepared beam profile measurement software and piezo drivers



# Mexican Hat Mirror Production status (Alban)

A three step process:

- 1: General shape coating
- 2: Corrective treatment
- 3: HR Coating



The beam intensity profile is flat and then falls off much faster than a Gaussian  
 The beam diameter at the mirror can be as large as 50% of the mirror diameter

25% of the mirror surface is sampled (up from 2.2%)

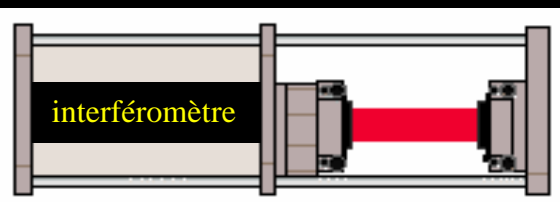
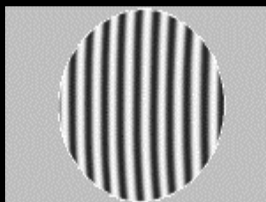
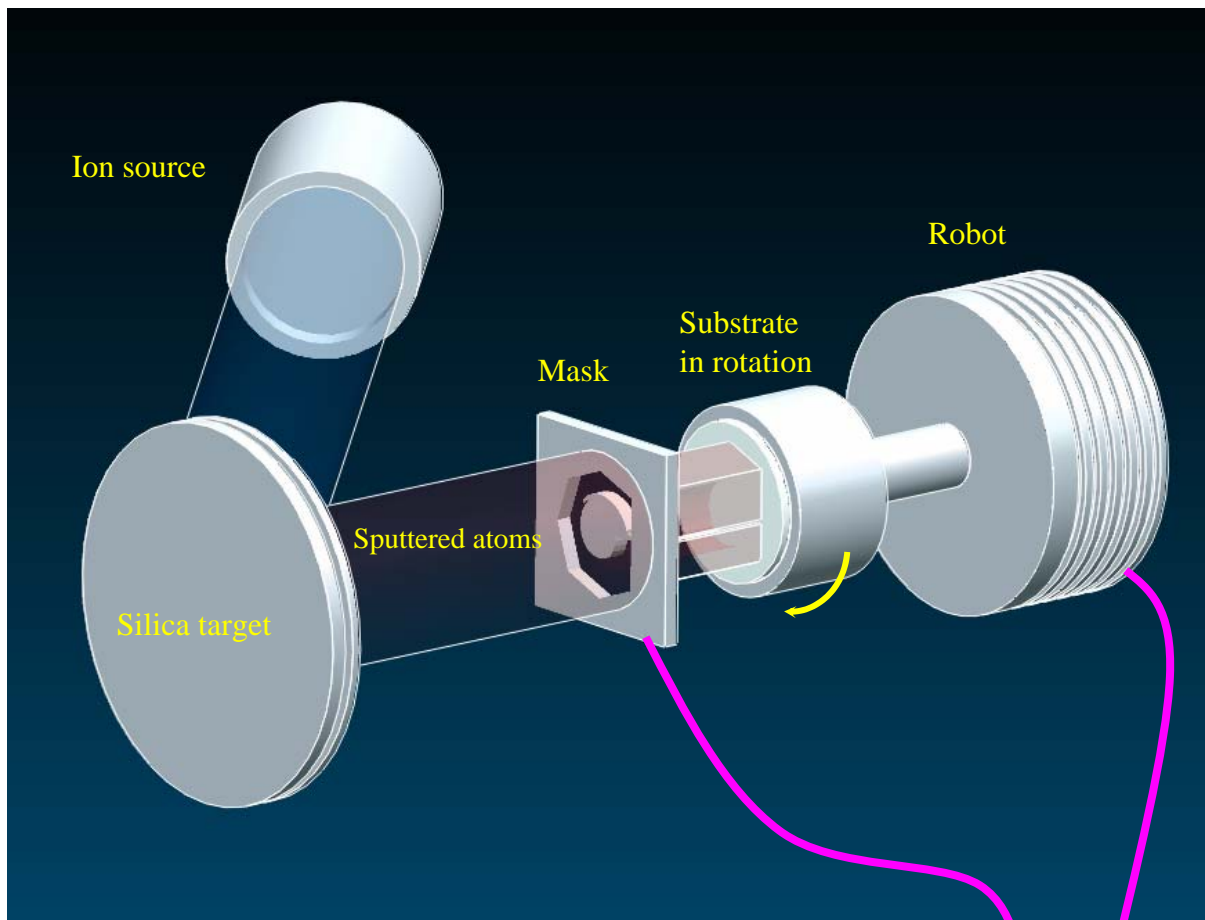
Much improved thermal noise performance

The mirror is not spherical! Manufactured with a special procedure

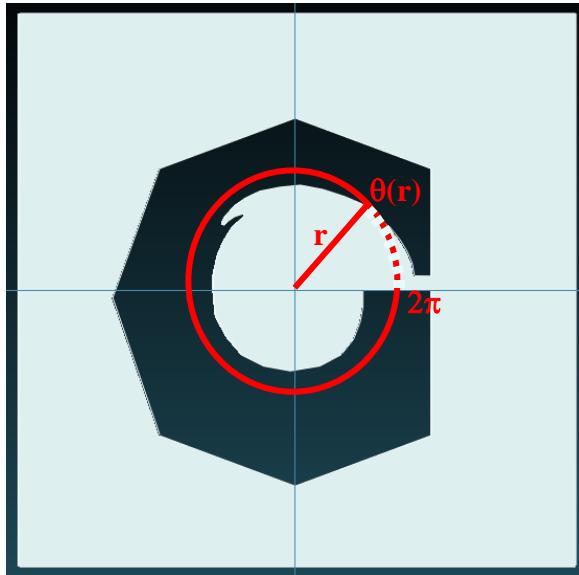
# 1: General shape coating

99%+ of the mirror Profile is generated with this Dead-Reckoning Deposition step

A mask between the ion source and the rotating beam substrate is calculated to deposit the required thickness where needed



# 1: General shape coating



Mask calculated so that :

The sputtered atom profile  
Generates the  
Mexican Hat profile

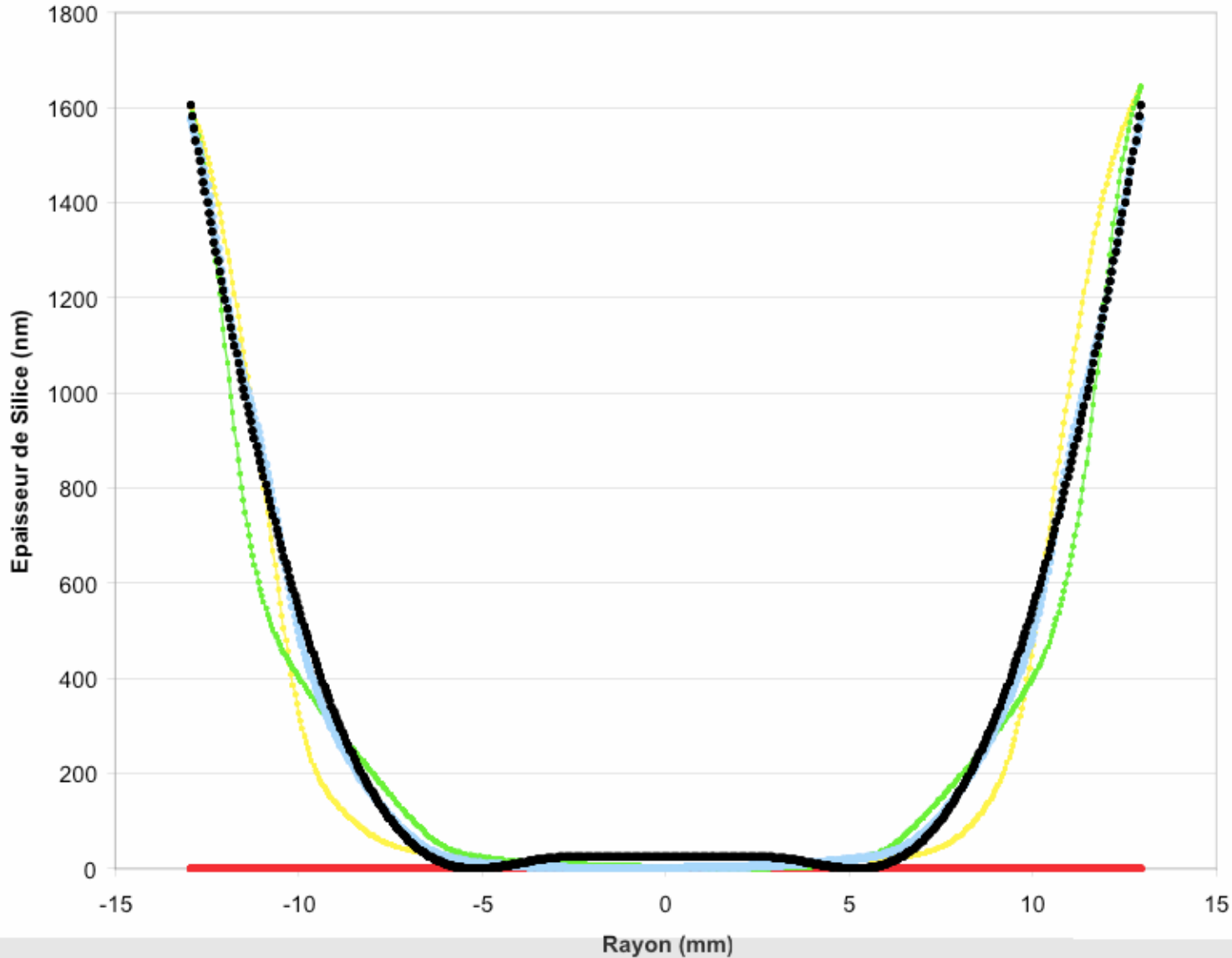
Assumption:

The axis of rotation of the substrate must be at the center of the mask

Problem **in first prototypes: rotation axis offset of 0.82 mm! (under vacuum)**  
**offset changing from run to run**  
eventually found and solved problem (more later)



# 1: General shape coating

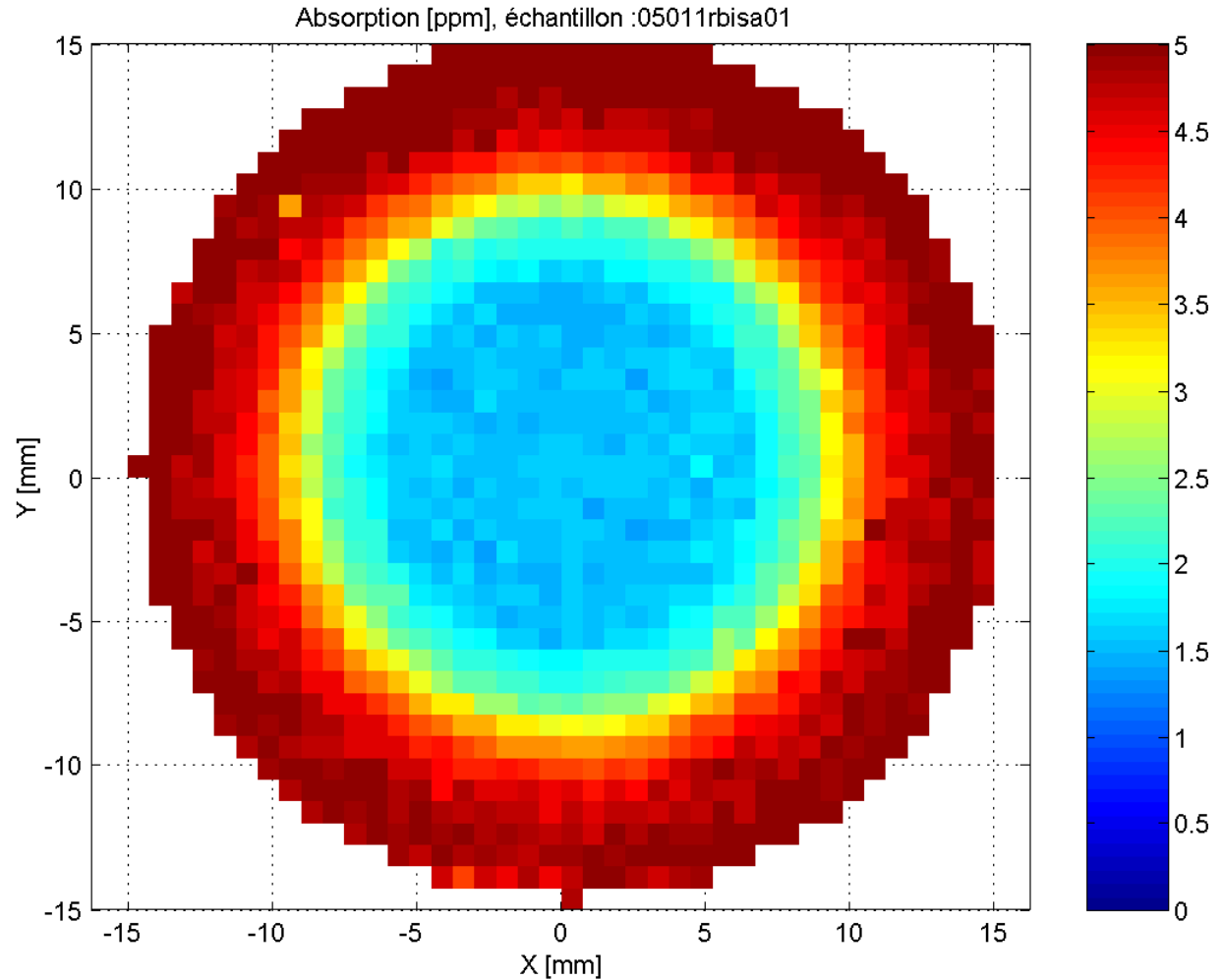




Absorption mapping  
of the general shape  
Coating

5 ppm OK

**BUT**



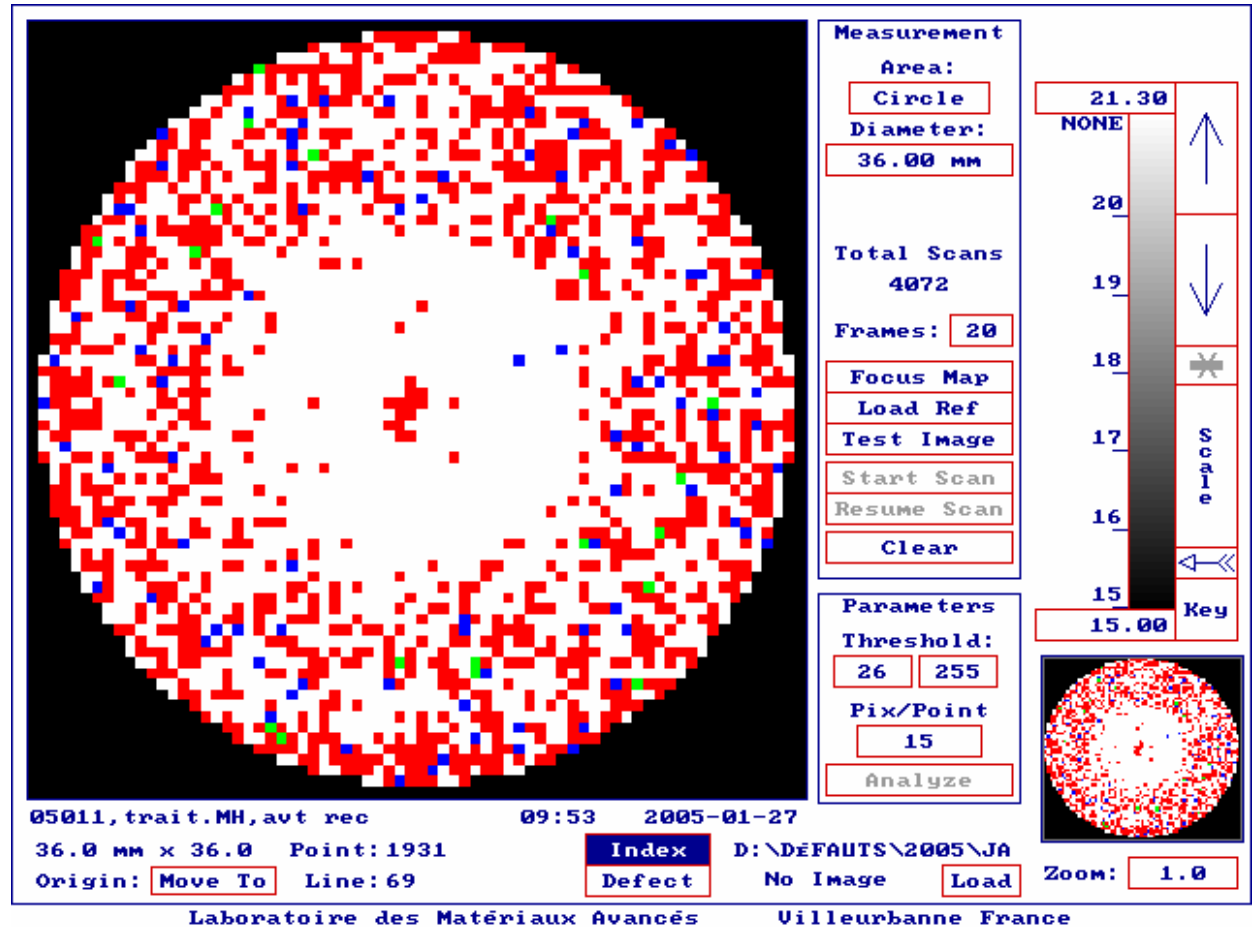
Extinction coefficient  $K=2.10^{-7}$



05011

Defect detection  
Before annealing

Unusually  
Large number of  
Defects generated



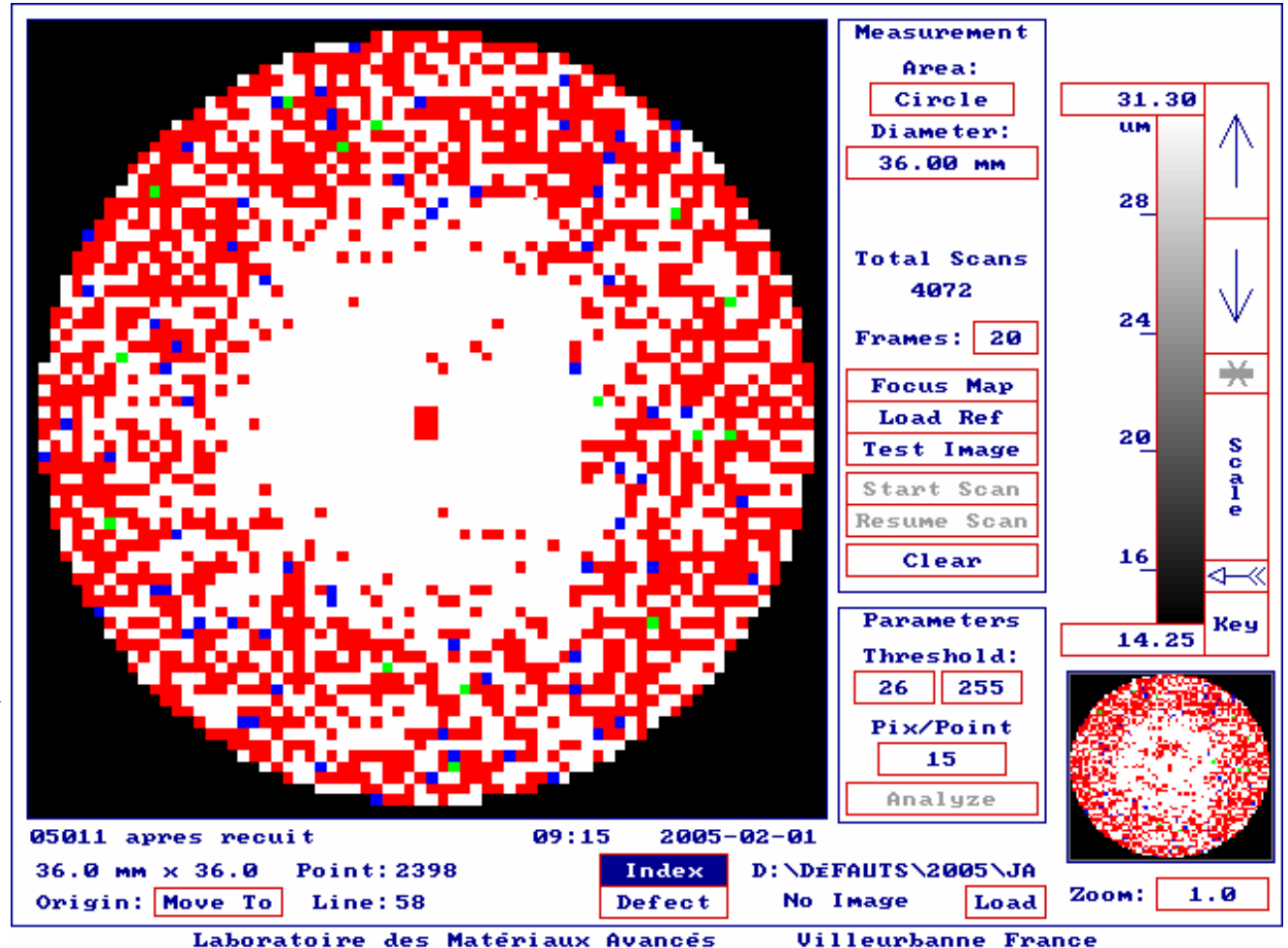
05011r

Defect detection  
After annealing

Even more defects  
Generated

Nucleation centers?

Problem from mask  
(More later)

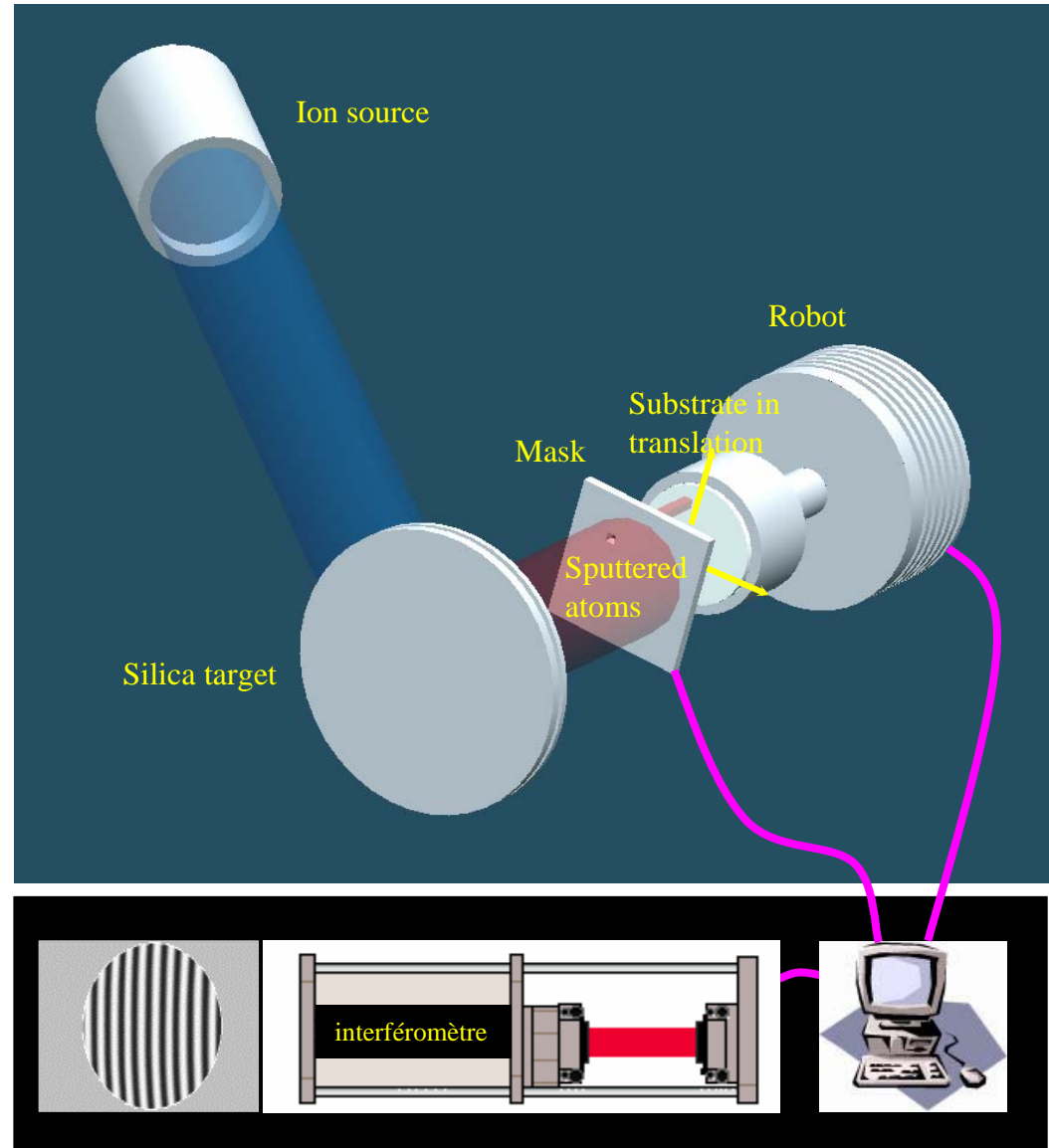


# 2: Corrective treatment

In this step the mirror profile generated by the general shape step is measured,

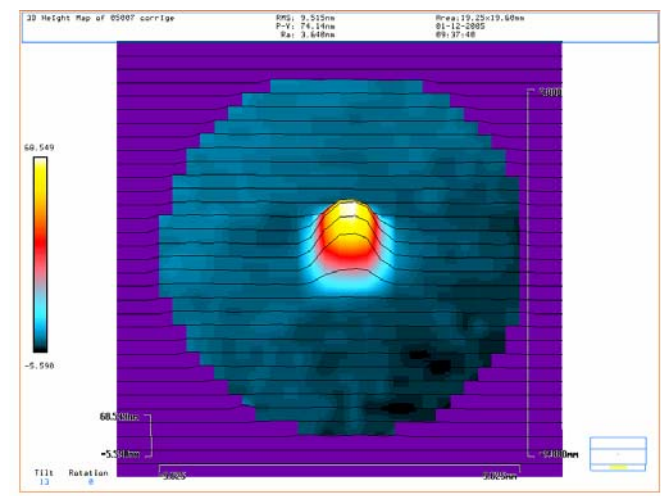
A map of its deviation from the ideal profile is generated

The deviations are corrected under numerical control with a SiO<sub>2</sub> molecular beam pencil

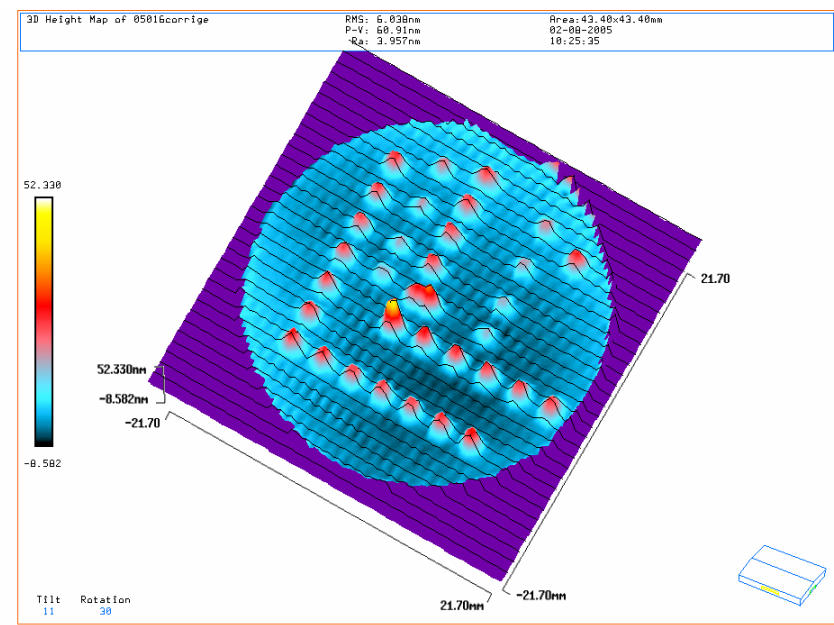


# 2: Corrective treatment

Measurement of the projection footprint of the pinhole that has been chosen for the corrective treatment.

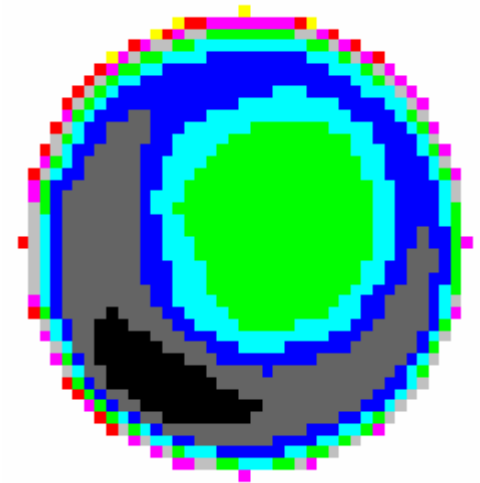
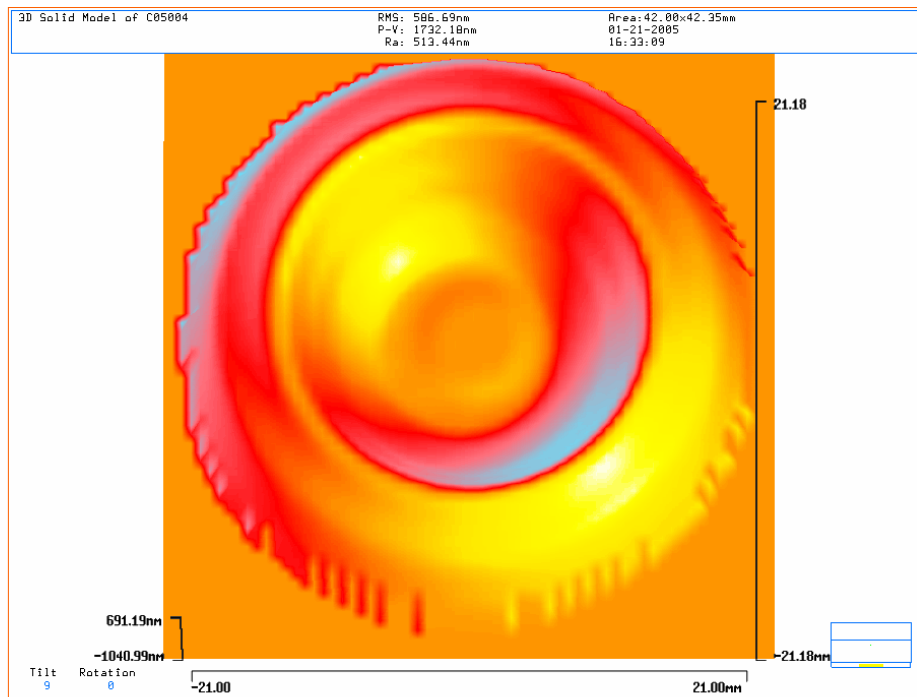


Measurement of the position of the Footprint for offset calibration.  
 Under vacuum, offset of several mm !



Title:	SMA-VIRGO	DATE: 02-08-2005 10:25:35
Part ID:	ADE/PHASE SHIFT	Wedge: Surface
Customer:	OptiCode - Phase Analyse Software	Polarity: +
Operator: Laurent Pinard	Version 4.23 (c) 1995-2000	
Terms Subtracted: Tilt		

First corrective attempt on a 20 mm thick substrate:



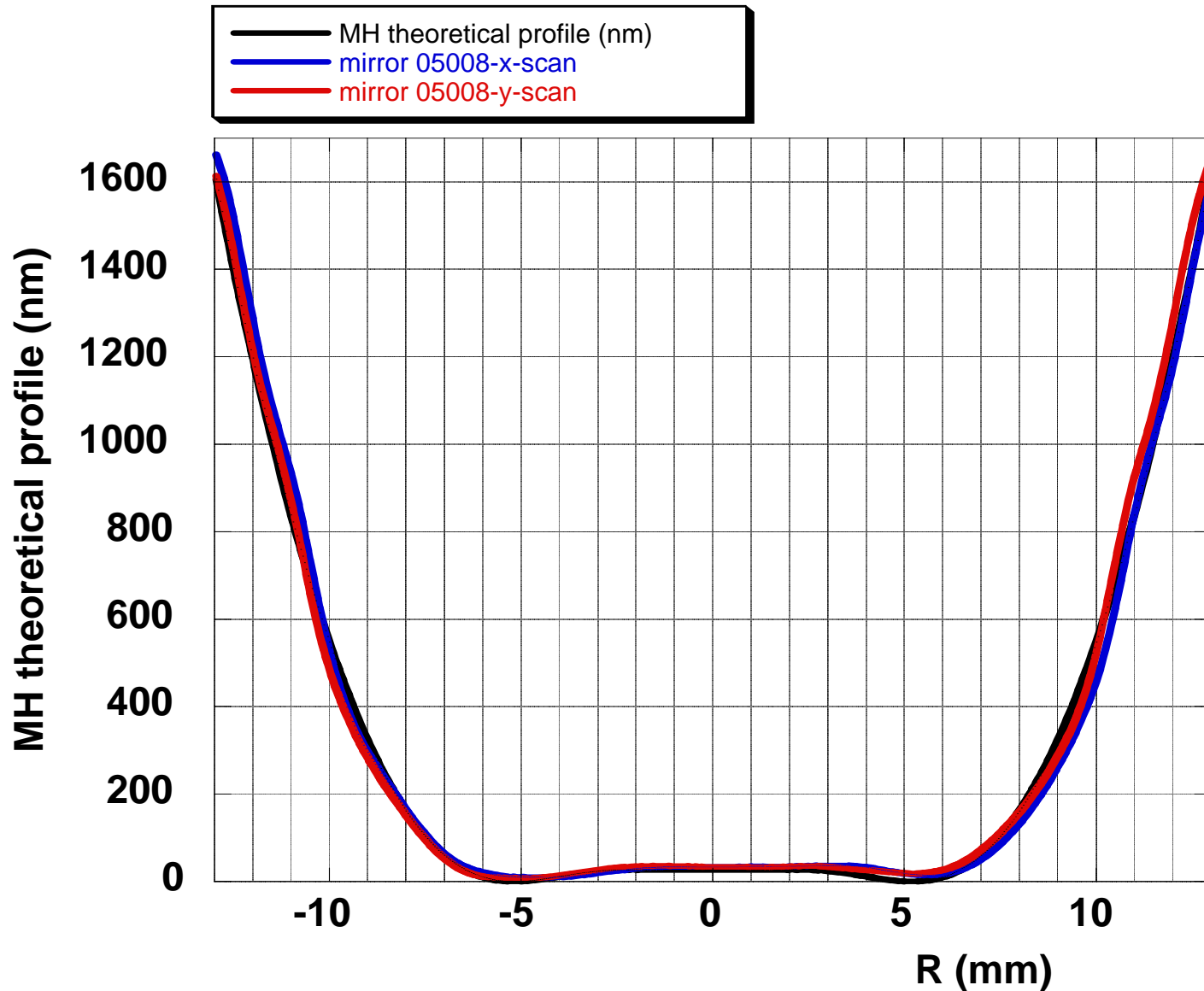
Again  
Offset of 0.9 mm on X !  
and 0.7 mm on Y !

Title:	SMA-VIRGO	DATE: 01-21-2005 16:33:09
Part ID:	ADE/PHASE SHIFT	Wedge: Surface
Customer:	OptiCode - Phase Analysis Software	Polarity: +
Operator: Laurent Pinard	Version 4.23 (c) 1995-2000	
Terms Subtracted: Tilt		



# 2: Corrective treatment

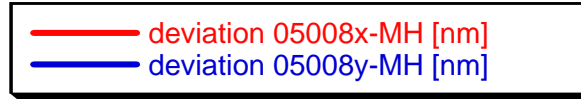
First attempt on a 20 mm thick substrate:





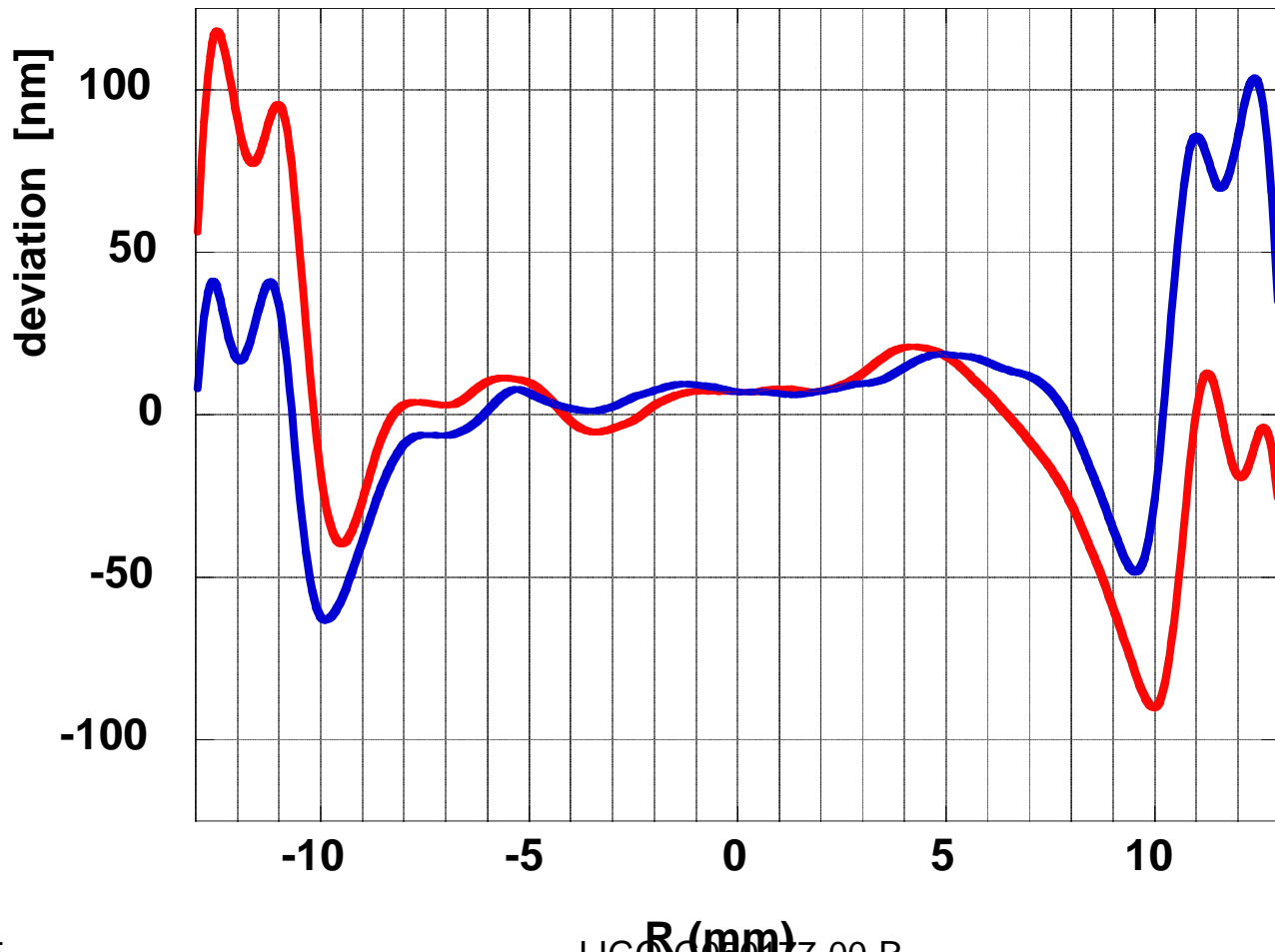
# 2: Corrective treatment

First attempt on a 20 mm thick substrate:



Deviation  
from target

results mex-hat







## 2: Corrective treatment

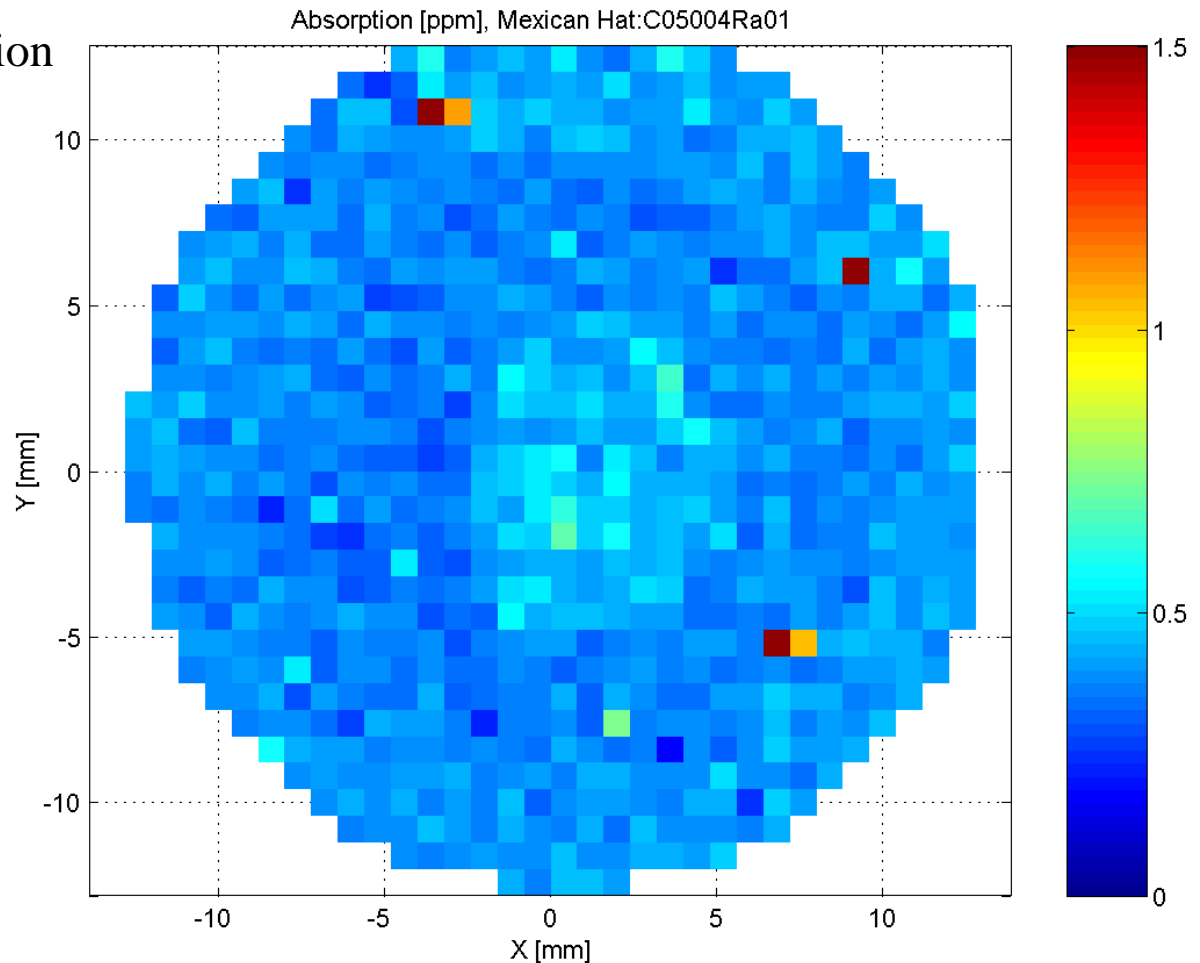
- The alignment problem has been found and fixed
- The precision movement corner was hitting on the closed vacuum chamber during calibration procedures

# 3: HR Coating

absorption map  
 on  $\varnothing$  26 mm : 0.5 ppm

At the center we guess a zone with corrective treatment with somewhat higher absorption (0.55 ppm).

Outside the central zone we have three absorption centers with 9, 16 and 26 ppm



# 3: HR Coating

Laboratoire des Matériaux Avancés -

C05004.10R

Wavelength  
= 1.0640  $\mu\text{m}$

Reflectance  
R = 1.0088

Angles:  
 $\theta_i = 4.00^\circ$   
 $\theta_s = 14.00^\circ$   
 $\alpha = 0.00^\circ$

Spot Dia., mm  
= 1.000

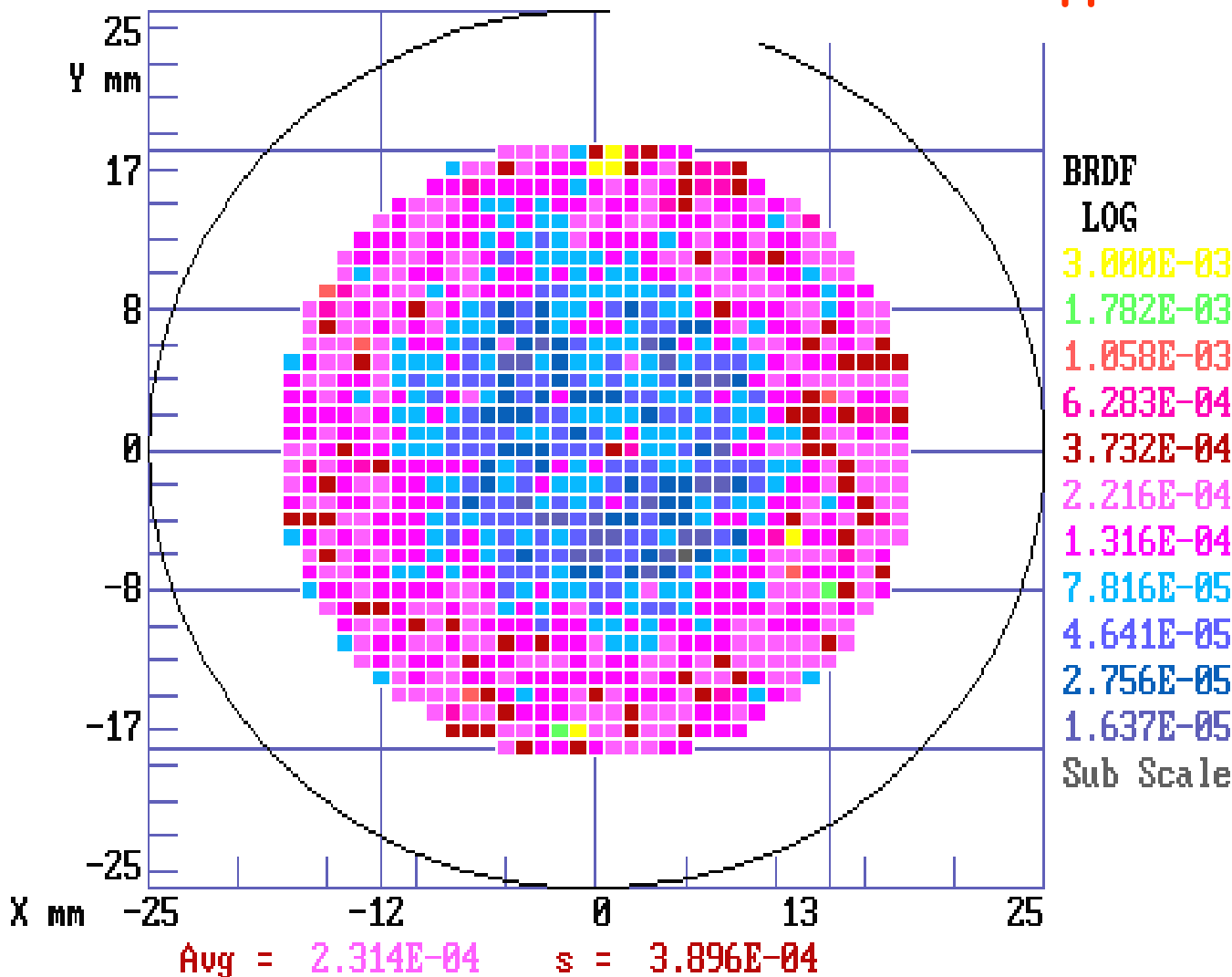
Step Size, mm  
= 1.000

Scan Ctr., mm  
X = 0.000  
Y = 0.000

Diffusion map (marker down)

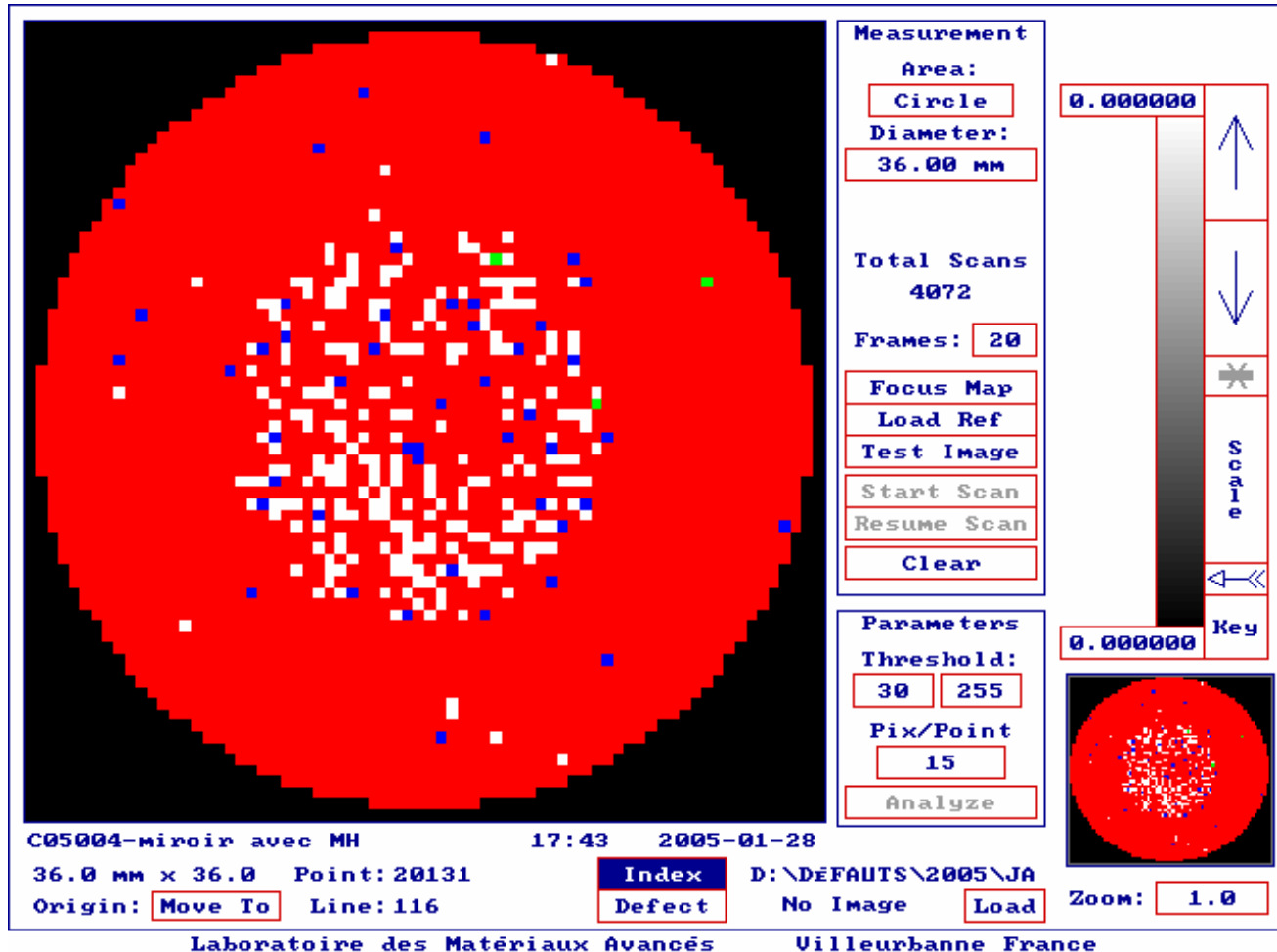
on  $\varnothing$  36 mm : 150 ppm

on  $\varnothing$  20 mm : 50 ppm



# 3: HR Coating

Defect detection  
 Again unusual  
 Defect  
 production



Measurement  
 Area: Circle  
 Diameter: 36.00 mm

Total Scans  
 4072

Frames: 20

Focus Map  
 Load Ref  
 Test Image  
 Start Scan  
 Resume Scan  
 Clear

Parameters  
 Threshold: 30 255  
 Pix/Point: 15  
 Analyze

Scale  
 0.000000  
 0.000000  
 Key

Zoom: 1.0

C05004-miroir avec MH 17:43 2005-01-28  
 36.0 mm x 36.0 Point: 20131  
 Origin: Move To Line: 116  
 Index Defect  
 D:\DEFAULTS\2005\JA No Image Load  
 Laboratoire des Matériaux Avancés Villeurbanne France



# 3: HR Coating

Transmission map (2° incidence)

1009 ppm

Laboratoire des Matériaux Avancés - Villeurbanne - France

TC05004C.10R

Wavelength  
= 1.0640 μm

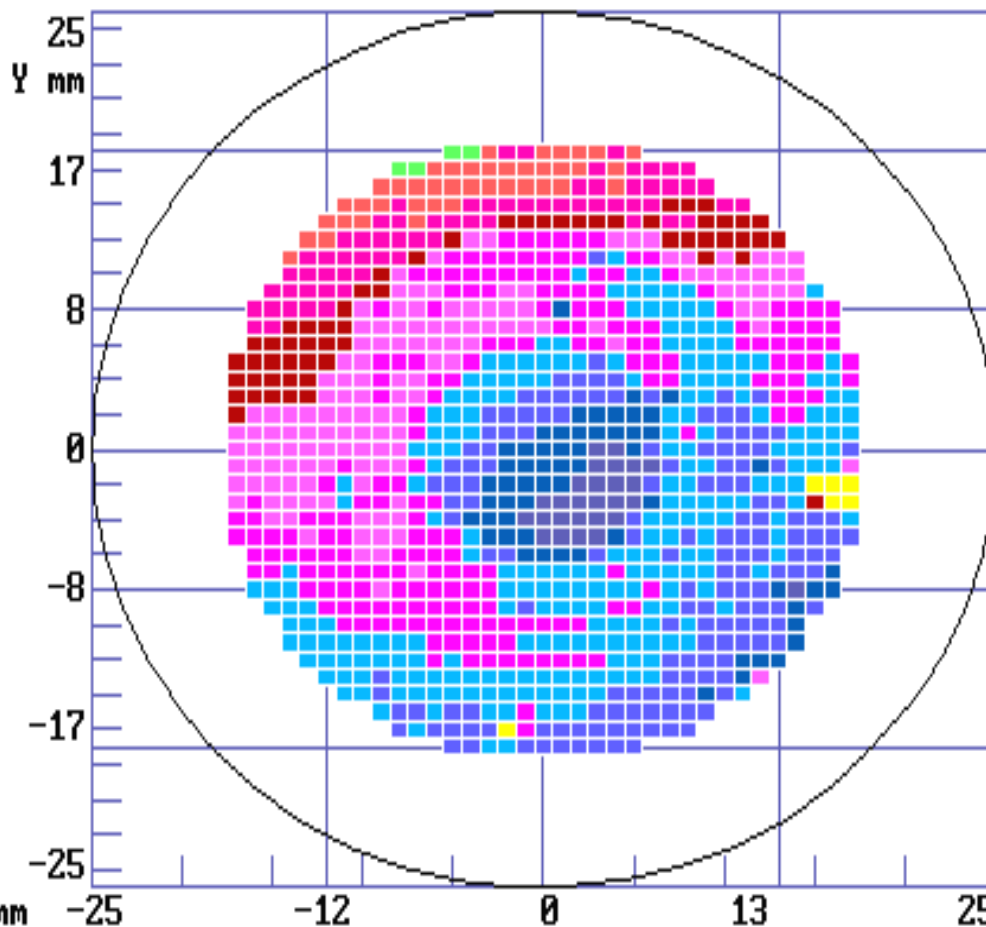
Reflectance  
R = 0.0010

Angles:  
θ<sub>i</sub> = 2.00°  
θ<sub>s</sub> = 2.00°  
α = 0.00°

Spot Dia., mm  
= 1.000

Step Size, mm  
= 1.000

Scan Ctr., mm  
X = 0.000  
Y = 0.000



Ref 1  
LOG  
 1.050E-03  
 1.039E-03  
 1.028E-03  
 1.017E-03  
 1.006E-03  
 9.956E-04  
 9.851E-04  
 9.747E-04  
 9.644E-04  
 9.542E-04  
 9.441E-04  
 Sub Scale

Avg = 1.009E-03 s = 3.653E-04



## 3: HR Coating

The slope (50 ppm variation between the two edges) is due to a difference of thickness deposited during the deposition of the reflective coating (the mirror was not properly rotating during HR deposition).

Next time, this asymmetry will not be present.

A (HB)11HBB mirror (run C05004) has been coated on the previous MH profile (05008)

- Absorption is good, 0.5 pmm
- The Transmission is around 1000 ppm, as specified.
- Diffusion is bad 50 ppm on 20 mm diameter  
(150 ppm on 36 mm diameter).
- Diffusion is much higher than usual (a few ppm).
- The quality of the silica deposited is not good,

# More on mirror manufacturing

- The high diffusion and absorption losses are probably due to material ripped off the masks by the passing molecular beam thus generating nucleation centers
- Lots of time spent in solving this problem
- Sharp edge coated masks used in future
- Problem diminishing with larger sizes



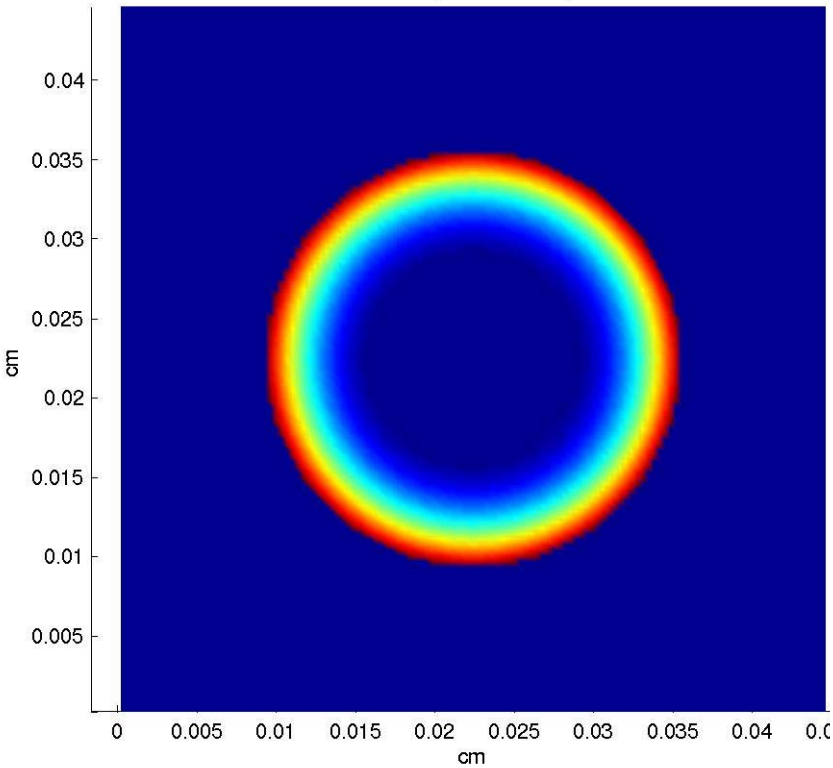


# Evaluation of expected performance of first pre-prototype

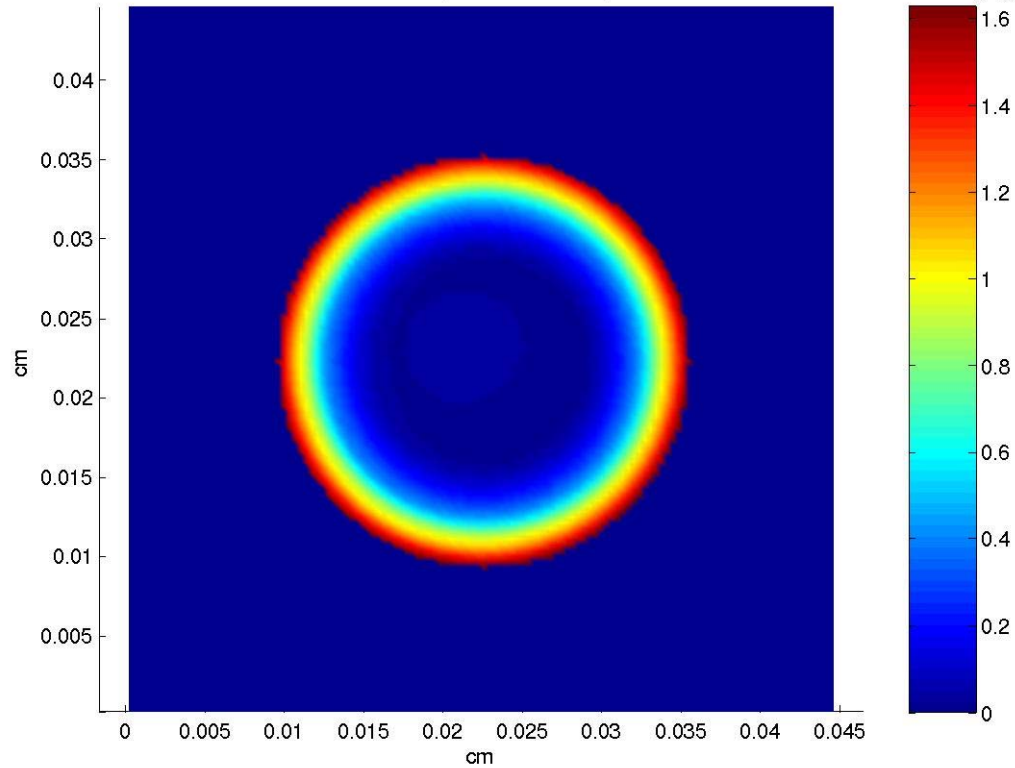
# Mirror prototype analysis (Erika and Juri)

- Required and first prototype mirror shape

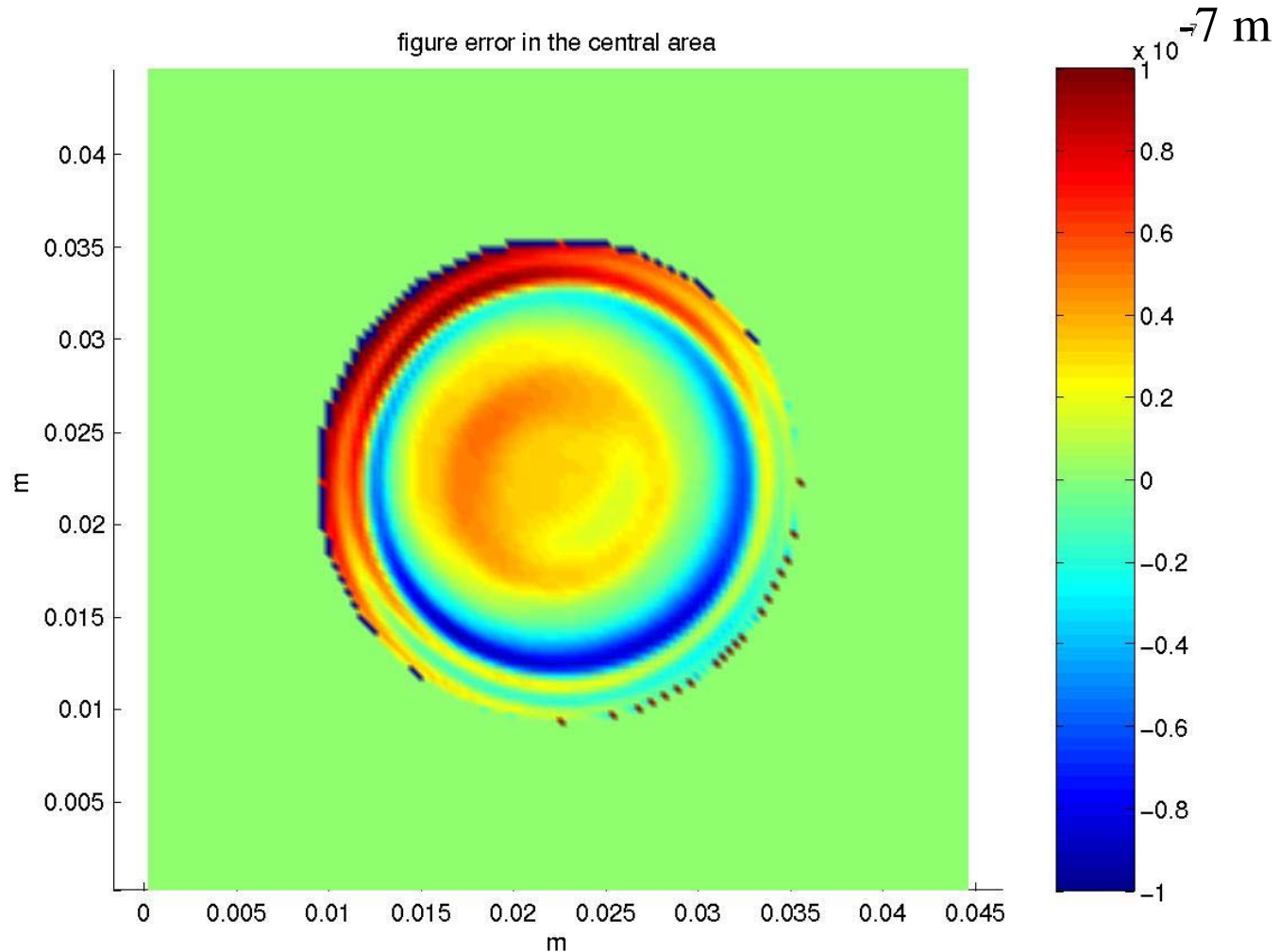
ideal mirror profile: as computed



real mirror profile: first attempt



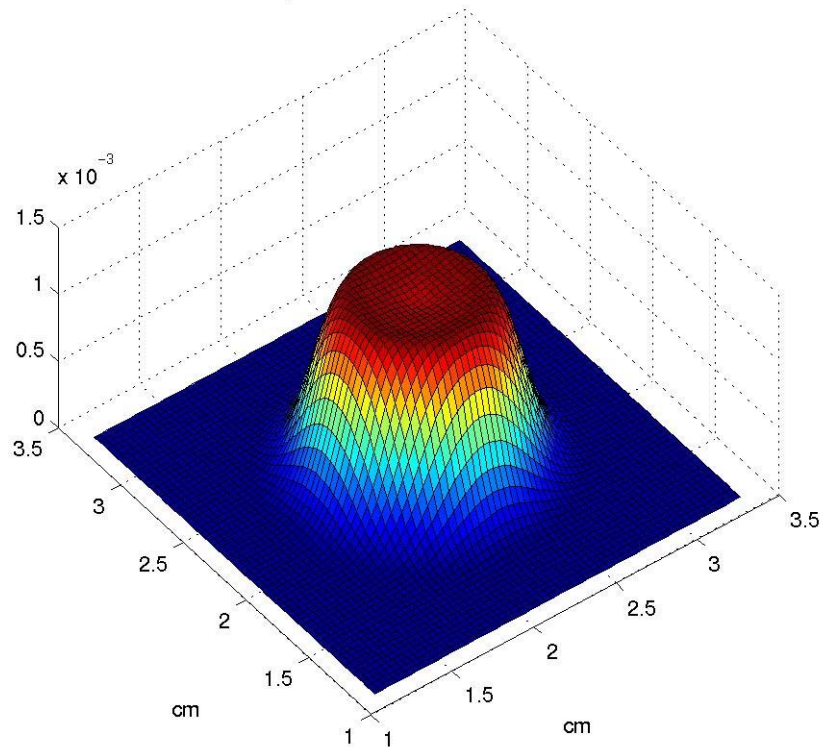
# Deviation from ideal (first proto)



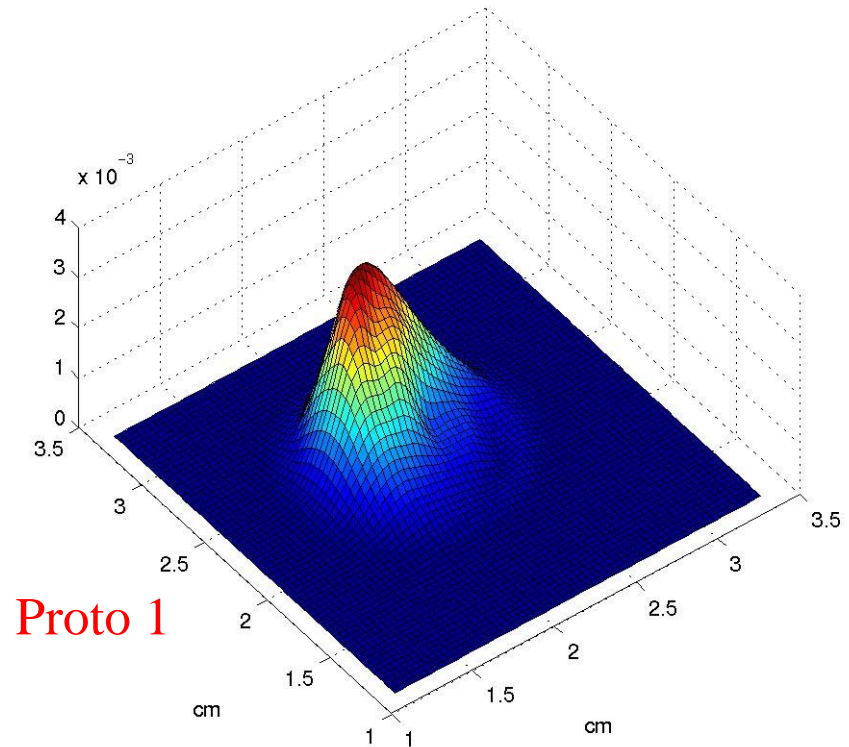
# Simulated effects on beam profile

- Ideal and first prototype beam profile

Cavity field for a locked ideal resonator



Cavity field for a locked real resonator



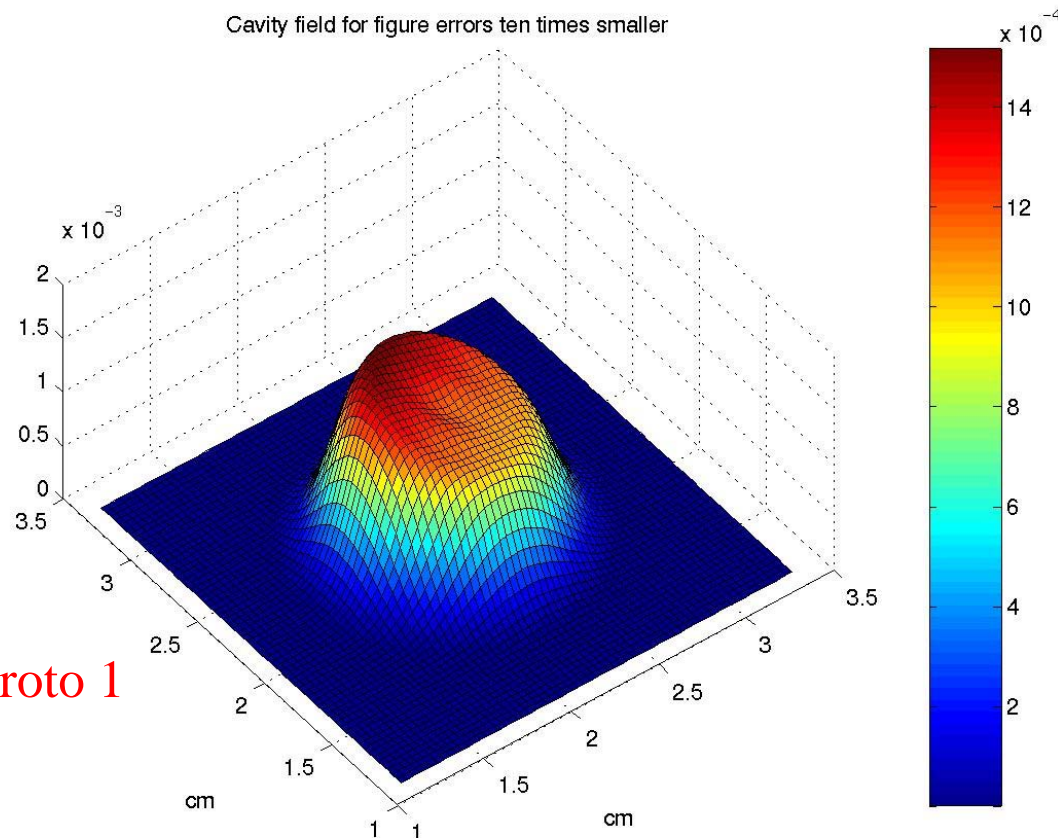


# Erika's Alignment strategy

- Using perturbation theory to determine the ideal realignment
- Apply 10% of deviation on an ideal mirror
- Simulate beam profile of “improved” mirror
- Calculate correction tilt with perturbation theory, observe and optimize effect
- Apply 10x tilt on original mirror and calculate effect

# Alignment strategy

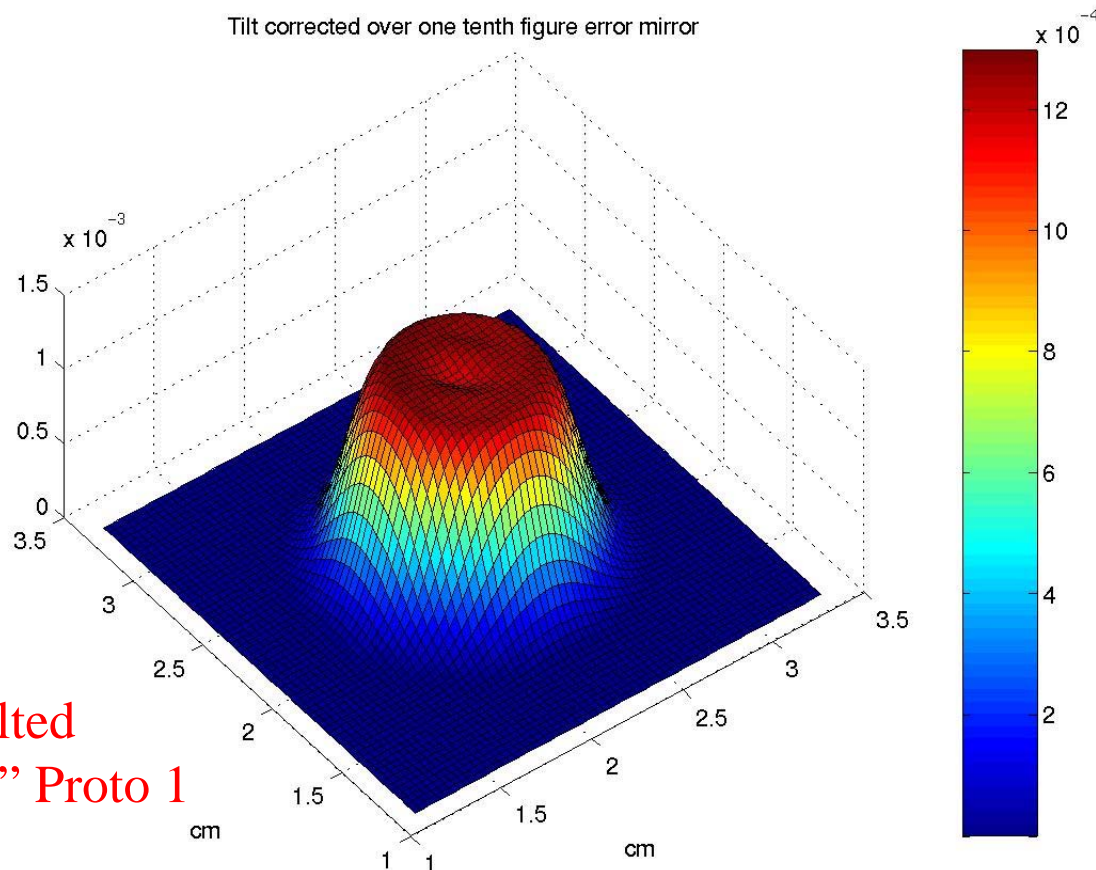
- Apply 10% of deviation on ideal mirror
- Simulate beam profile of “improved” mirror



“improved” proto 1

# Alignment strategy

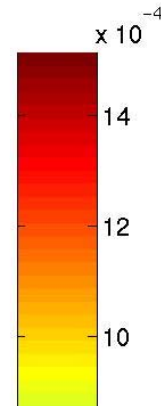
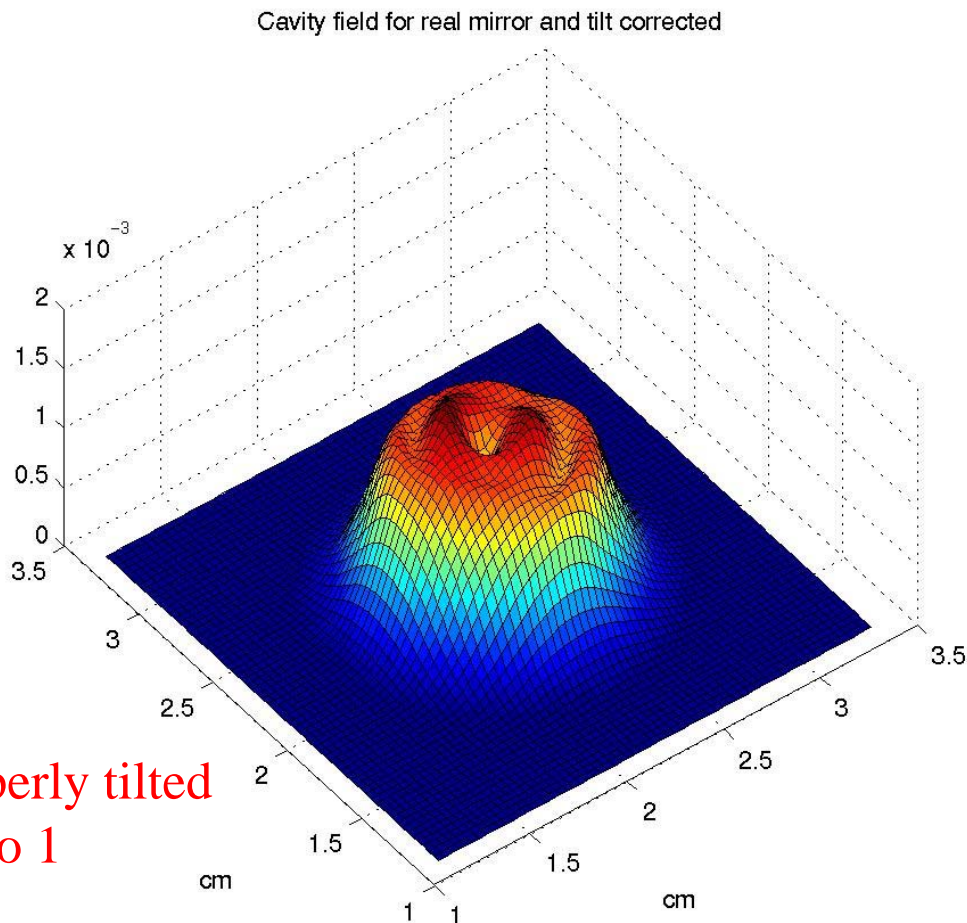
- Calculate correction tilt with perturbation theory, observe and optimize effect



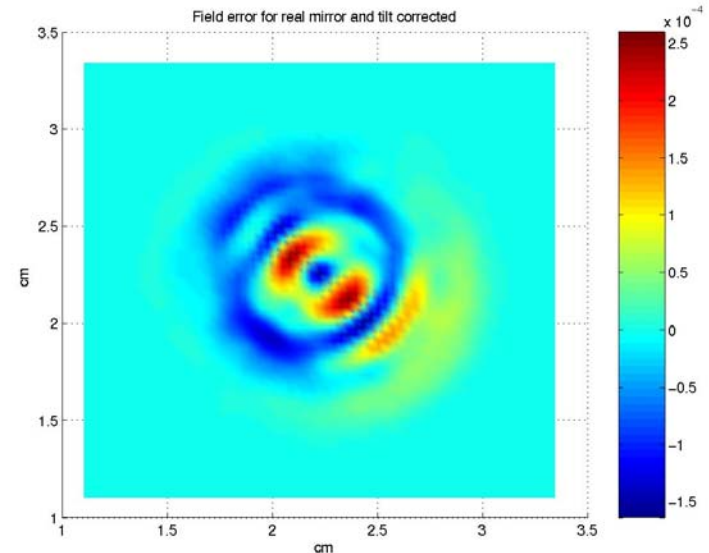
Properly tilted  
“improved” Proto 1

# Alignment strategy

Apply 10x tilt on original mirror and calculate effect on beam



Variations from ideal beam profile



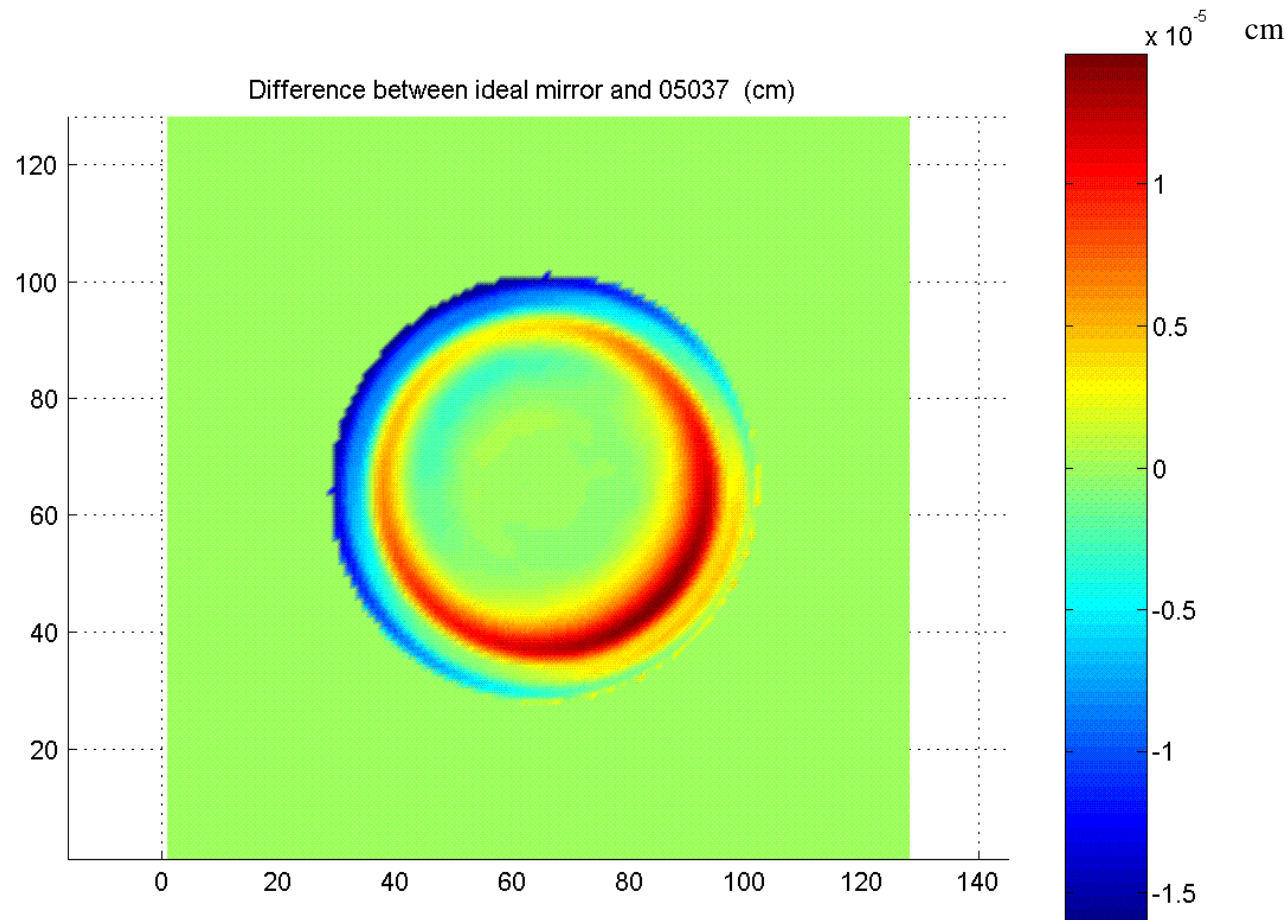
Properly tilted  
Proto 1



# First production item

## preliminary

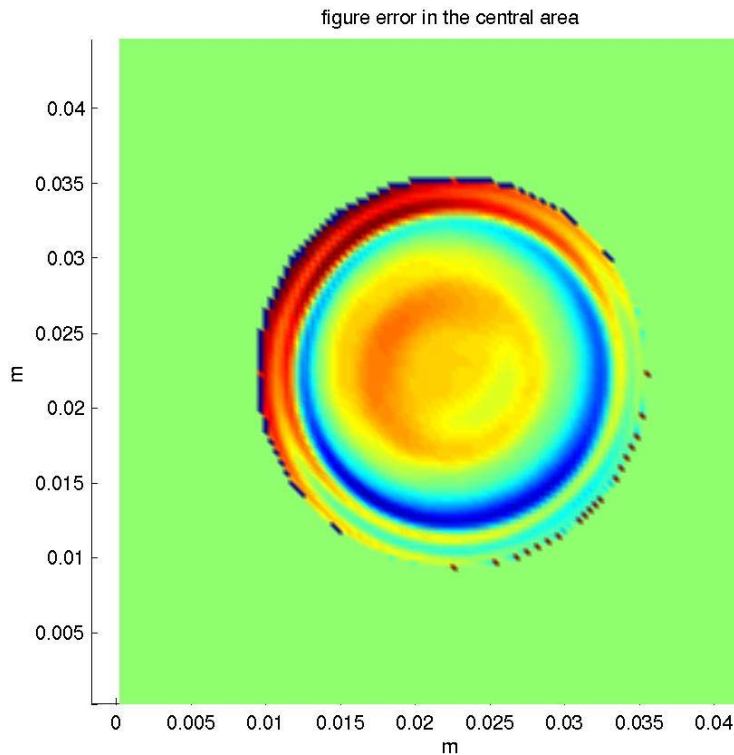
- Unfinished
- General coating only !  
no corrective coating yet !!!
- Deviations from ideal profile



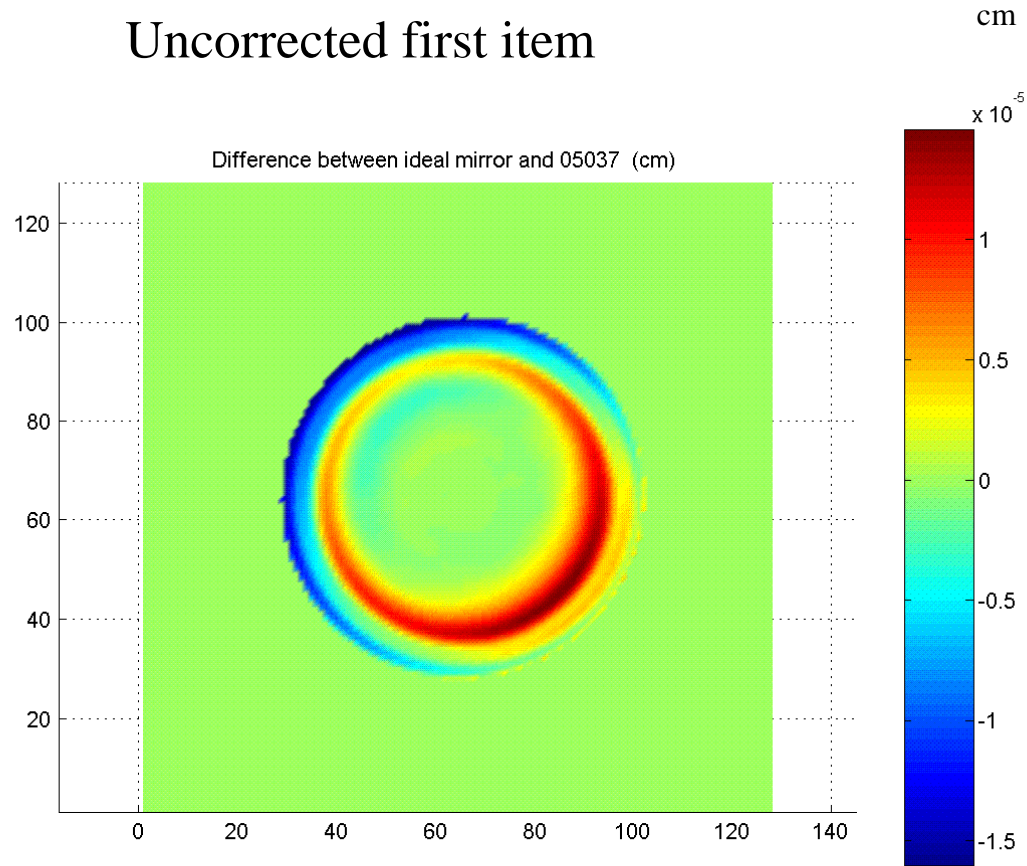
# First production item

## preliminary

Finished pre-prototype



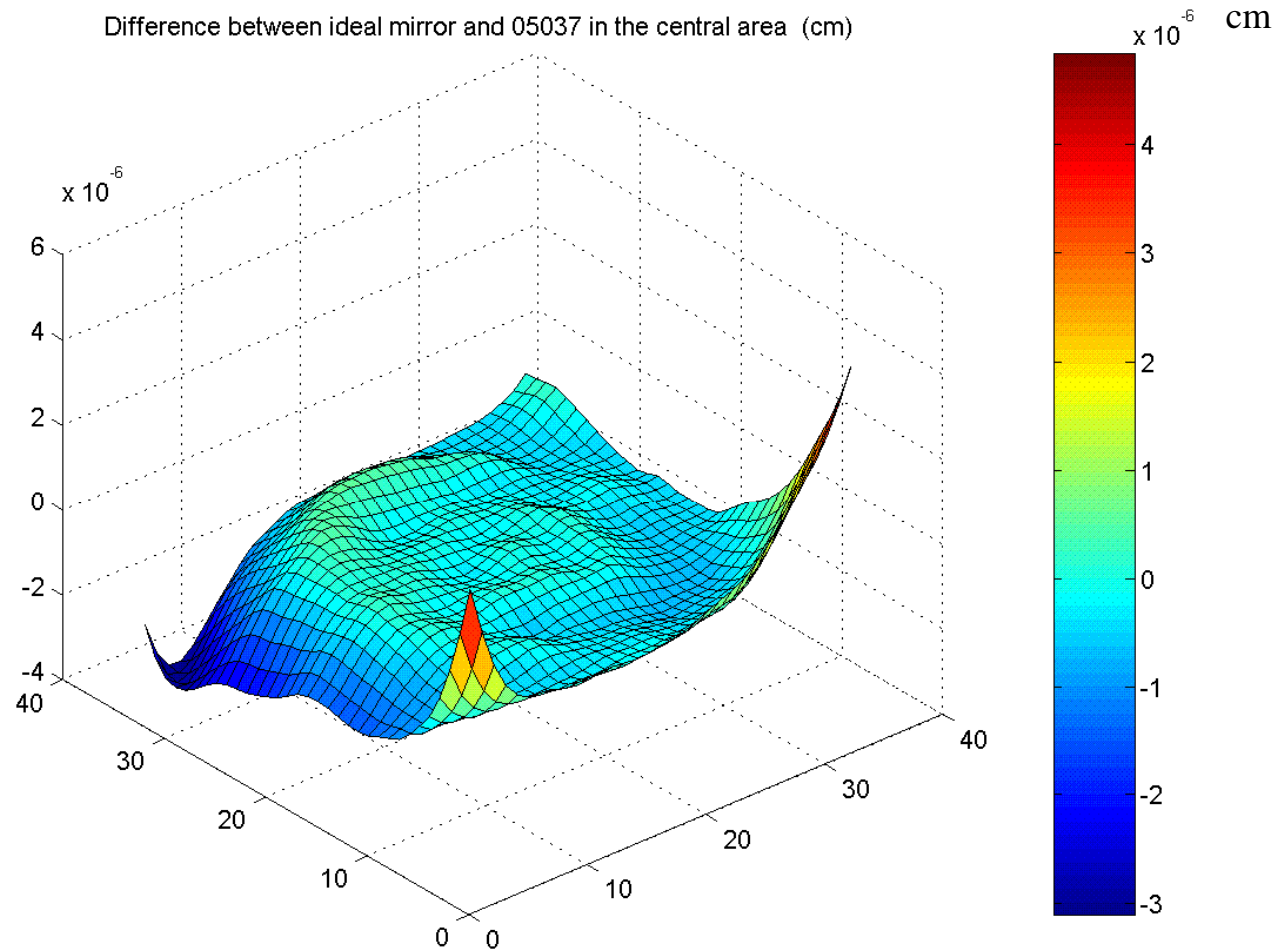
Uncorrected first item



# First production item

## preliminary

- Unfinished
- General coating only !  
no corrective coating yet !!
- Deviations from ideal profile





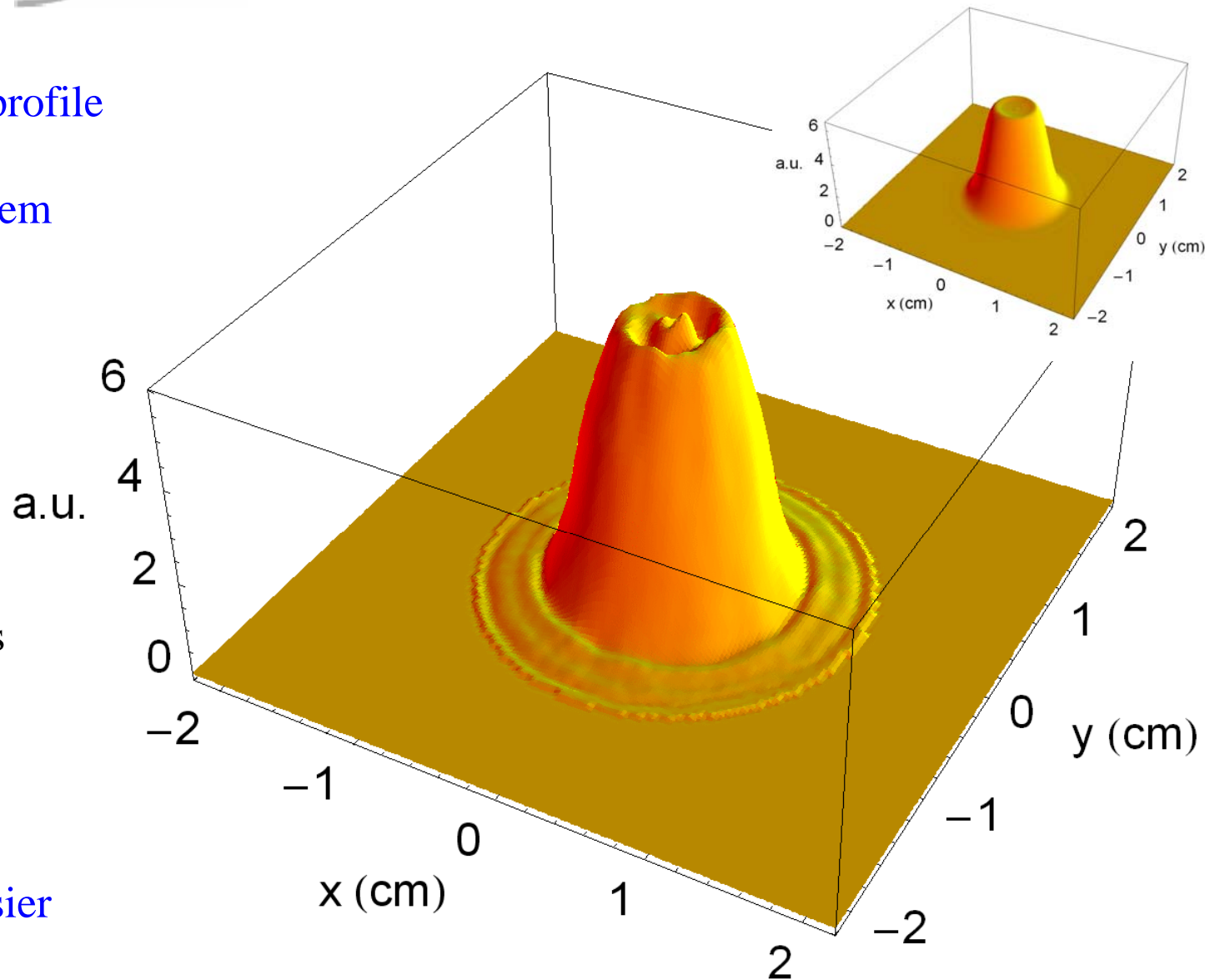
# First production item

Calculated beam profile  
With unfinished  
First production item  
MH mirror

The corrective  
Coating steps  
Is expected to  
Further improve

Long long process  
But approaching  
Manufacturing  
Success

Larger mirrors easier





# Conclusions

- MH mirrors have been successfully manufactured
- Lots of problems but the production items will be greatly improved
- Even the first prototype would be satisfactory !!
- Look forward for installation on interferometer of both first prototype and first production MH mirrors to verify the simulation results
- The MH beam interferometer will soon come back online and make a real test the new mirrors



# Next steps

- Study the static and dynamic properties of the FT beams
- Study the problem of producing MH mirrors for concentric cavities
- Design a TN interferometer for MH mirrors